

P27195.A01

IFW



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Toshiharu FURUKAWA

Group Art Unit: 1756

Serial No: 10/711,758

Examiner: Unassigned

Filed: October 4, 2004

For: **REDUCED MASK COUNT GATE CONDUCTOR DEFINITION**

**SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT**

Commissioner for Patents  
U.S. Patent and Trademark Office  
Customer Service Window, Mail Stop Amendment  
Randolph Building  
401 Dulany Street  
Alexandria VA 22314

Sir :

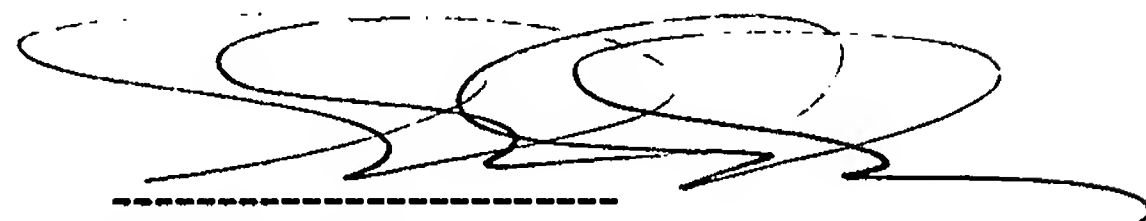
Under the provisions of 37 CFR § 1.97 through § 1.99 and pursuant to applicant's duty of disclosure under 37 CFR § 1.56, applicant respectfully brings the following documents, listed on the attached form PTO-1449, to the attention of the Examiner in charge of the above-identified application. A copy of the cited documents is enclosed for the convenience of the Examiner.

This citation does not constitute an admission that the references are relevant or material to the claims. They are only cited as constituting related art of which the applicant is aware.

P27195.A01

It is respectfully requested that the listed references be considered by the Examiner and formally made of record in this application.

Respectfully submitted,  
Toshiharu FURUKAWA

A handwritten signature in black ink, appearing to read 'Andrew M. Calderon', with a horizontal dashed line underneath it.

Andrew M. Calderon  
Reg. No.:38,093

March 31, 2005  
GREENBLUM & BERNSTEIN, P.L.C.  
1950 Roland Clarke Place  
Reston, VA 20191  
(703) 716-1191

FORM PTO-1449

U.S. Department of Commerce  
Patent and Trademark OfficeAtty. Docket No.  
P27195Application No.  
10/711,758INFORMATION DISCLOSURE STATEMENT  
BY APPLICANT

(Use several sheets if necessary)

Applicant  
Toshiharu FURUKAWAFiling Date  
October 4, 2004Group  
1756

## U.S. PATENT DOCUMENTS

| EXAMINER<br>INITIAL | DOCUMENT NUMBER | DATE | NAME | CLASS | SUBCLASS | FILING DATE<br>IF<br>APPROPRIATE |
|---------------------|-----------------|------|------|-------|----------|----------------------------------|
|                     |                 |      |      |       |          |                                  |
|                     |                 |      |      |       |          |                                  |
|                     |                 |      |      |       |          |                                  |
|                     |                 |      |      |       |          |                                  |
|                     |                 |      |      |       |          |                                  |
|                     |                 |      |      |       |          |                                  |
|                     |                 |      |      |       |          |                                  |
|                     |                 |      |      |       |          |                                  |
|                     |                 |      |      |       |          |                                  |
|                     |                 |      |      |       |          |                                  |

## FOREIGN PATENT DOCUMENTS

| DOCUMENT NUMBER | DATE | COUNTRY | CLASS | SUBCLASS | TRANSLATION<br>YES NO |
|-----------------|------|---------|-------|----------|-----------------------|
|                 |      |         |       |          |                       |
|                 |      |         |       |          |                       |
|                 |      |         |       |          |                       |
|                 |      |         |       |          |                       |
|                 |      |         |       |          |                       |
|                 |      |         |       |          |                       |
|                 |      |         |       |          |                       |
|                 |      |         |       |          |                       |
|                 |      |         |       |          |                       |

## OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

|   |  |
|---|--|
| 1 | M.L. Kerbaugh, et al. "A Method of Sidewall Image Transfer Utilizing the Polyimide-Nitride Material Interaction", Research Disclosure, February 1988, Number 286.                                      |
| 2 | Anonymous, "Process and Mask Structure for Submicrometer-wide Polysilicon or Polycide Emitters", February 1987. Research Disclosure Database Number: 274061, Research Disclosure Journal Number: 27461 |
| 3 | J.E. Cronin, "Method for Making a Single Sidewall Structure", IBM Technical Disclosure Bulletin, Vol. 30, No. 12, May 1988, pp. 157-158.   |
|   |  |
|   |  |
|   |  |

EXAMINER

DATE CONSIDERED

\*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.